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· · · · · · · · · · · · · · · · · · ·	Application No.	Applicant(s)
Notice of Allowability	10/705,864 Examiner	DOI, SATOSHI Art Unit
	William M. Brewster	2823
The MAILING DATE of this communication ap All claims being allowable, PROSECUTION ON THE MERITS I herewith (or previously mailed), a Notice of Allowance (PTOL-8 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.3	S (OR REMAINS) CLOSED in th 5) or other appropriate communic RIGHTS. This application is sub	is application. If not included cation will be mailed in due course. THIS
1. X This communication is responsive to 13 November 2003	<b>).</b>	
2. 🔀 The allowed claim(s) is/are <u>1-14</u> .		
3. $igotimes$ The drawings filed on <u>13 November 2003</u> are accepted t	by the Examiner.	
<ul> <li>4.</li></ul>	ave been received.  Ave been received in Application Note the attached EXAM ives reason(s) why the oath or departs the submitted.  Because of this communication to file a summer of this application.  Committed Note the attached EXAM ives reason(s) why the oath or departs the submitted.  Because of this communication to file a summer of the attached EXAM ives reason(s) why the oath or departs the submitted.  Because of this communication to file a summer of the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) why the oath or departs the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s) which is a summer of the attached EXAM ives reason(s	No  In this national stage application from the reply complying with the requirements  INER'S AMENDMENT or NOTICE OF eclaration is deficient.  PTO-948) attached  the Office action of
each sheet. Replacement sheet(s) should be labeled as such in 7. DEPOSIT OF and/or INFORMATION about the dep	n the header according to 37 CFR 1 posit of BIOLOGICAL MATER	I.121(d). IAL must be submitted. Note the
attached Examiner's comment regarding REQUIREMEN	II FOR THE DEPOSIT OF BIOL(	JGICAL MATERIAL.
Attachment(s)	_	
1. Notice of References Cited (PTO-892)		mal Patent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948	Paper No./Ma	nil Date
<ol> <li>Information Disclosure Statements (PTO-1449 or PTO/SE Paper No./Mail Date <u>111303</u></li> </ol>	3/08), 7. ⊠ Examiner's An	nendment/Comment
4.   Examiner's Comment Regarding Requirement for Deposition  Example Requirement Regarding Requirement for Deposition  Example Requirement Regarding Requirement for Deposition  Example Regarding Requirement Regarding Requirement for Deposition  Example Regarding Regarding Requirement Regarding Reg	<del>_</del>	atement of Reasons for Allowance
of Biological Material	9. 🗌 Other	

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## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

a) In the Title

Insert: --Method for Forming-- before "Interconnections"

## Reasons for Allowance

The following is an examiner's statement of reasons for allowance: in claim 1, lines 6-22 cannot be found in the prior art of record. The prior art of record fails to teach, in combination, the process features.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to William M. Brewster whose telephone number is 571-272-1854. The examiner can normally be reached on Full Time.



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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

10 November 2004

William M. Brewster

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